

## MINDO/3 Prediction of the $\Pi$ and $\Sigma$ Electronic States of the Succinimido Radical

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**Synopsis.** Restricted open-shell SCF MINDO/3 calculation gives the  $\Sigma$  state for the electronic ground state of the succinimido radical.

Recent works on the succinimido radical<sup>1)</sup> has yielded a number of interesting characterizations of this radical. One of these is the recognition that two different electronic states of succinimido are being produced in the reactions of *N*-halosuccinimides, radicals with quite distinctive properties. These are considered to be the  $\Pi_N$  and  $\Sigma_N$  states.<sup>2)</sup> Succinimido has not been detected by ESR experiment<sup>1)</sup> and the theoretical work of this radical is worth being done.

In the simplest nitrogen radical,  $\text{NH}_2$ , the lone-pair electrons occupy the hybrid  $\sigma$  orbital of nitrogen and an unpaired electron occupies the nitrogen  $2p_\pi$  orbital; the  $\Pi$  state is the ground state and the  $\Sigma$  state is an excited one. The *ab initio* calculation<sup>3)</sup> gives 113  $\text{kJ mol}^{-1}$  for the energy separation between these states; the experimental value is 130  $\text{kJ mol}^{-1}$ .<sup>3)</sup> The same level of the *ab initio* calculation<sup>3)</sup> gives 46  $\text{kJ mol}^{-1}$  for the  $\Sigma_N$ - $\Pi_N$  energy separation of the formylaminy ( $\text{HCONH}$ ) radical. In formylaminy, the carbonyl  $\pi^*$  orbital stabilizes the nitrogen  $2p_\pi$  electrons, and the  $\Sigma$ - $\Pi$  energy separation is reduced by the amount of 67  $\text{kJ mol}^{-1}$ . In the succinimido radical, two carbonyl groups are introduced at the nitrogen atom, and its  $\Sigma$ - $\Pi$  separation would be reduced still more; there is the possibility that the ground state of succinimido is of the  $\Sigma$  type.<sup>4)</sup>

Koenig and Wielsek<sup>5)</sup> have done the INDO calculation on the succinimido radical and concluded that the  $\Pi$  state is the ground state. Their results show that the energy separation between the  $\Sigma_N$  and  $\Pi_N$  states is 159  $\text{kJ mol}^{-1}$ . This value is too large and inconsistent with the above qualitative consideration about the  $\Sigma$ - $\Pi$  energy separation of the nitrogen radicals. We have thus examined the energy separation of succinimido using the MINDO/3 approximation.<sup>6)</sup> The  $\Sigma$  and  $\Pi$  states of succinimido were obtained by repeated diagonalization of the correct general SCF operator which gives the optimum results for the open-shell systems.<sup>7)</sup> The molecular structure was optimized by the use of Fletcher's variable metric method.<sup>8)</sup> For the  $\text{NH}_2$  radical, MINDO/3 gave the satisfactory molecular structures and the  $\Sigma$ - $\Pi$  energy separation (Table 1). The optimized structures and the calculated heats of formation of succinimido are shown in Fig. 1. The MINDO/3 predicts the  $\Sigma$  ground state for the succinimido radical. This state lies 71  $\text{kJ mol}^{-1}$  below the excited  $\Pi$  state.

Very recently, on the basis of the semi-empirical MNDO calculations, Clark<sup>9)</sup> has well explained the reaction paths for the generation of the  $\Pi$  and  $\Sigma$  states of the succinimido radical from *N*-halosuccinimides. His MNDO results show that the ground

TABLE 1. MINDO/3 RESULTS ON THE  $\text{NH}_2$  RADICAL

Method	H-N-H angle/ $^\circ$		$E(\Sigma) - E(\Pi)$ $\text{kJ mol}^{-1}$
	In $\Pi$ state	In $\Sigma$ state	
MINDO/3	102	136	100
STO-3G <sup>a)</sup>	101	130	188
4-31G <sup>a)</sup>	108	143	113
Experimental <sup>a)</sup>	103	144	$\approx 130$

a) From Ref. 3.

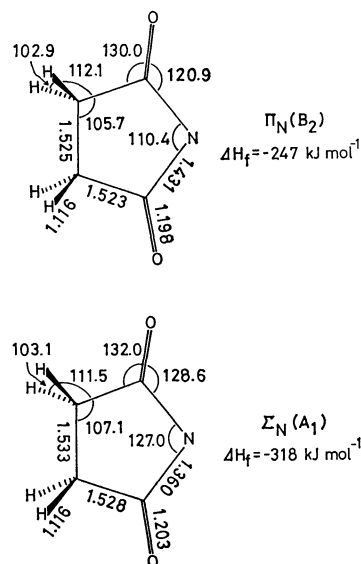


Fig. 1. The molecular structure ( $C_{2v}$ ) of the  $\Pi$  and  $\Sigma$  states of the succinimido radical optimized by the restricted open-shell MINDO/3 method. These  $C_{2v}$  structures were also obtained by the geometry optimization in which the distorted ( $C_s$ ) structures were used as the initial data.

state of succinimido is of  $\Pi$ -type, although the open-shell method employed is an approximate one. Since the present MINDO/3 calculation predicts the  $\Sigma$  ground state which is inconsistent with the INDO and MNDO results, another semi-empirical method, the CNDO/BW method<sup>10)</sup> which was parametrized by Boyd and Whitehead so as to give better energetics of molecules, was also applied to succinimido. The results obtained are parallel with those of MINDO/3; the  $\Sigma$  state is more stable than the  $\Pi$  state by 41  $\text{kJ mol}^{-1}$ .

The characterization of the ground and excited electronic states of the succinimido radical is a key factor for the analysis of the reaction mechanism in which both of the ground and excited states of succinimido are involved. The present MINDO/3 and CNDO/BW results predict the  $\Sigma$  state for the ground state of this radical, while the INDO<sup>5)</sup> and MNDO<sup>9)</sup>

calculations have predicted the  $\Pi$  ground state. The  $\Sigma$ - $\Pi$  separation of succinimido is expected to be very small, and the question, whether  $\Sigma$  or  $\Pi$  is the ground state of this radical, is still open to investigation.

#### References

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